



Dual Taper Nose

Biplanar Expansion

TiCell® Nano Surface Technology

Integrated Grafting Technique

Open Architecture



Dual Taper Nose

The Exceed® implant features a Dual Taper Nose offering a reduced insertion profile in two planes to reduce neural retraction, bony resection, and ease insertion into tight disc spaces.

- Dual taper design reduces profile in two planes for easy implant insertion
- · Leading edge is 6mm smaller than final height
- · Insert to desired posterior disc height

Dual taper reduces profile in two-planes

Insert to desired posterior disc space height

Biplanar Expansion

The Exceed® implant offers biplanar expansion with a simple, confirmable technique.

Width Expansion

- Increases implant footprint for enhanced stability
- Maximizes available graft space and graft window
- Allows for increased endplate surface area and reduces the risk of subsidence



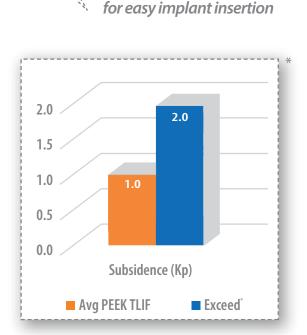
- Restores sagittal balance offering 0°, 8°, and 15° lordotic options
- Optimized Fit
- Resists retropulsion

Width expansion creates graft window allowing for increased surface area reducing the risk of subsidence





Biplanar anterior expansion with a simple confirmable technique



Open Architecture

The Exceed® implant is designed with strategic use of titanium providing an open architecture.

- Large graft chamber and graft entry portal for unrivaled grafting into and through the implant
- Less implant material provides improved radiographic visibility of the fusion mass







Very large graft chamber



Streamlined Procedure

Exceed® features simple, and reliable instrumentation designed to improve workflow.

 One pass by the nerve root to insert, expand, and deliver graft

• Simple, powerful, and confirmable implant expansion

 Integrated, through-inserter, grafting solution provides fast, safe, and easy graft insertion using the GraftMag® EX Graft Delivery System

• No posterior backflow of graft material



Fast, safe, easy bone graft insertion using the integrated GraftMag®EX Graft Delivery System

Completely and easily fill the expanded implant, and the evacuated disc space with bone graft, post-placement





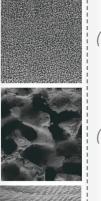


TiCell®Nano

Advanced Surface Technology

TiCell® Nano Surface Technology is a proprietary advanced surface technology that uses a 2-Stage Laser Ablation process that creates porosity, micro roughness, and nanoscale features.





(20x)

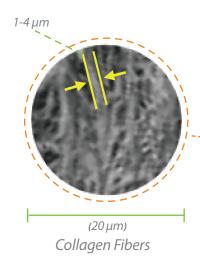
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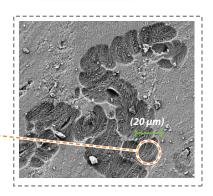
(10,000x)

(40,000x)

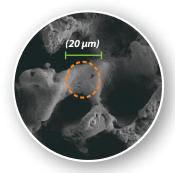
Emulating Nature by Advanced Laser Technology

	Human Bone Tissue**	TiCell® Nano*
Collagen Fiber	1-4 μm	1-2 μm
Collagen Fibril	10-300 nm	50-100 nm

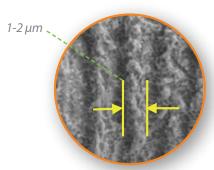




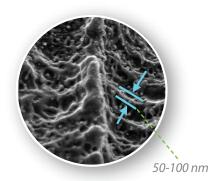
Osteoclastic Pits



TiCell[®] Nano



TiCell® Nano

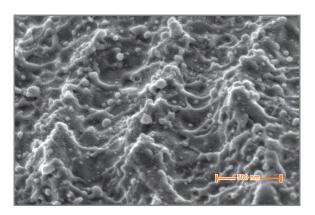


TiCell[®] Nano (150,000x)

Titanium Implant Surfaces

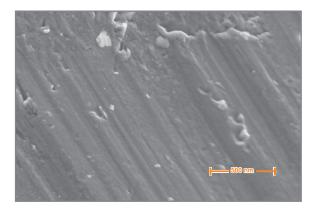
Nano-scale comparison

(All images 75,000X, scale bars = 500nm)

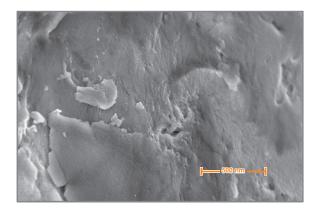


TiCell® Nano Advanced Surface Technology

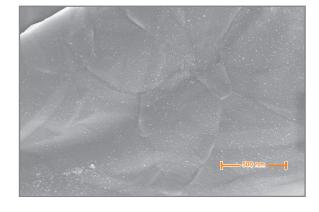
(75,000x)



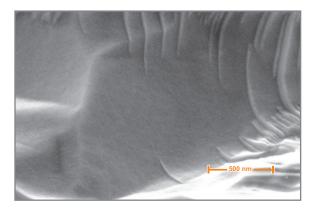
3D Printed Titanium (75,000x)



Machined Titanium (75,000x)



Plasma Spray Titanium (75,000x)



Acid Etched Titanium (75,000x)



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^{*}Data on File at Spine Wave

^{**}Shinya Watari et al "Modulation of osteogenic differentiation in hMSCs cells by submicron topographically-patterned ridges and grooves" Biomaterials. 2012 January; 33(1): 128–136. doi:10.1016/j.biomaterials.2011.09.058.